

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	("5270843").PN.	US-PGPUB; USPAT	OR	OFF	2005/08/04 10:24
L2	8	(phase near delay) same (polymer near (liquid adj crystal))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:00
L3	62	tune\$3 near (liquid adj crystal)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:00
L4	21	3 and polymer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:07
L5	16299	(polymer near (liquid adj crystal))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:08
L6	2779	(polymer adj dispersed adj (liquid adj crystal))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:08
L7	133	6 and (polar\$5 adj beam adj split\$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:27
L8	1	6 same (polar\$5 adj beam adj split\$5)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:10
L9	85	6 and (polar\$5 adj beam adj split\$5) and prism	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 11:51

L10	1	("20040105048").PN.	US-PGPUB; USPAT	OR	OFF	2005/08/04 12:26
L11	0	6 and (phtolithography)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:26
L12	286	6 and (photolithography)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:34
L13	208	6 and (photolithography) and (mask)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:42
L14	1	6 and (photolithography) and (phase near mask)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:27
L15	1	6 same (photolithography and mask)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:39
L16	4	6 same (photolithography)	US-PGPUB; USPAT	OR	ON	2005/08/04 12:39
L17	38	(polymer near region) and ((liquid adj crystal) near region) and photolithography	US-PGPUB; USPAT	OR	ON	2005/08/04 12:45
L18	41	(polymer near region) and ((liquid adj crystal) near region) and photolithograph\$3	US-PGPUB; USPAT	OR	ON	2005/08/04 12:59
L19	26	(polymer near region) and ((liquid adj crystal) near region) and photolithograph\$3 and mask	US-PGPUB; USPAT	OR	ON	2005/08/04 12:47
L20	18744	(photolitho\$8 and (pattern\$5 adj2 mask))	US-PGPUB; USPAT	OR	ON	2005/08/04 13:02
L21	41	20 and 6	US-PGPUB; USPAT	OR	ON	2005/08/04 13:00
L22	44	(photolithograph\$5 same 5)	US-PGPUB; USPAT	OR	ON	2005/08/04 13:08
L23	11	(photolithograph\$5 same 6)	US-PGPUB; USPAT	OR	ON	2005/08/04 13:05
L24	12	(photolithograph\$5 same 6)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 13:05
L25	44	22 not 24	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 13:06

L26	44	22 not 23	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/04 13:06
L27	24	(photolithograph\$5 same 5) and mask	US-PGPUB; USPAT	OR	ON	2005/08/04 13:15
L28	24820	(photolithograph\$5 with mask)	US-PGPUB; USPAT	OR	ON	2005/08/04 13:15
L29	200	28 and 5	US-PGPUB; USPAT	OR	ON	2005/08/04 13:18
L30	91	28 and 6	US-PGPUB; USPAT	OR	ON	2005/08/04 13:21
L31	4	28 same 5	US-PGPUB; USPAT	OR	ON	2005/08/04 13:18
L32	1	"20050099662"	US-PGPUB; USPAT	OR	ON	2005/08/04 13:39
L33	77	(polarization adj beam adj split\$5) and 6	US-PGPUB; USPAT	OR	ON	2005/08/04 13:50
L34	4	(polarization adj beam adj split\$5) same 6	US-PGPUB; USPAT	OR	ON	2005/08/04 13:39
L35	4947	cell adj gap	US-PGPUB; USPAT	OR	ON	2005/08/04 13:52
L36	258	35 and 6	US-PGPUB; USPAT	OR	ON	2005/08/04 13:50
L37	384	(cell adj gap) with (micron micrometer)	US-PGPUB; USPAT	OR	ON	2005/08/04 13:52
L38	31	37 and 6	US-PGPUB; USPAT	OR	ON	2005/08/04 14:01
L39	1	"20050099662"	US-PGPUB; USPAT	OR	ON	2005/08/04 14:01